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The structure of the bulk and the (001) surface of $V_2O_5$. A DFT+U study

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Abstract

GGA (PW91) + U is applied to the calculation of the structure (lattice parameters) and the electronic structure of the $V_2O_5$ bulk and its (001) surface for different values of $U_{\text{eff}}$ used in the literature (0.0, 3.0 and 6.6 eV). Similar surface lattice parameters are calculated for the (001) surface and for the bulk, as well as similar electronic structures. The calculated lattice parameters ($a$ and $b$ for the surface and $a$, $b$ and $c$ for the bulk) are in good agreement with experimental results. It seems that there is no strong correlation between the calculated lattice parameters and the value of $U_{\text{eff}}$. The calculated width of the valence band keeps the value of $\approx 5$ eV for the three studied $U_{\text{eff}}$. However, the energy gap between the valence and the conduction bands increases with the value of $U_{\text{eff}}$. $U_{\text{eff}} = 3.0$ eV seems to be the most adequate value to describe the energy gap after comparison with experimental results. Electronic density contour plots indicate that for a larger (smaller) $U_{\text{eff}}$ the accumulated charge in the V-O(1) bond is overestimated (underestimated). The contour plots (in the $a$ direction) show that the charge distribution V-O(3) is less correlated with $U_{\text{eff}}$ than the charge distribution V-O(1), whereas charge distribution V-O(2) seems not to be correlated with $U_{\text{eff}}$. The energy gap between the valence and the conduction bands seems to be strongly related with the charge distribution in the V-O(1) bond. The V-O(1) bond stability seems to be correlated with $U_{\text{eff}}$. However, the stability of the V-O(2) and V-O(3) bonds seems not to be strongly affected by $U_{\text{eff}}$.

1. Introduction

Vanadium oxides are used in the production of chemicals, in catalysis and batteries as well as other uses. The importance of the support in the catalitic properties of the vanadium oxides has also been outlined [1–28]. The bulk $V_2O_5$ and the $V_2O_6$(001) surface have been investigated using experimental and theoretical methods [29–34]. Several DFT methodologies have been applied to the optimization of the lattice parameters [30, 33–42]. Those calculations have been performed within the DFT framework with periodic boundary conditions. The $a$ and $b$ (in plane) lattice parameters are in good agreement with the experimental values in general [32]. The van der Waals interactions were included in some of the works in order to take into account the weak interactions between layers that gives a better agreement with the $c$ lattice parameter (perpendicular to the (001) surface).

Generalized gradient approach (GGA) and GGA+U methods were applied in order to calculate the energy for a number of oxidation reactions of 3d transition metal oxides [43]. In the article, the authors found that the use of the GGA+U method makes possible to address the correlation effects in the 3d transition metal oxides. The calculated oxidation energies agree well with experimental information for the values given to $U_{\text{eff}}$. They found that for many of the metal oxides they studied, the $U_{\text{eff}}$ value that corrects the oxidation energy also improves the magnetic moments and the band gaps. In particular, for $V_2O_3$ the calculated band gap is 1.6 and 2.1 eV using GGA and GGA+U methods, respectively; whereas 2.0 and 2.2 eV are experimental values according to references [44] and [45], respectively. They found a value of $U_{\text{eff}} \approx 3$ eV for a few vanadium oxides [43].
The value \( U_{\text{eff}} \approx 3 \text{ eV} \) [46] was also used to describe the surface metal-insulator transition of a \( V_2\text{O}_5(001) \) single crystal [47]. In the experimental study a reversible metal to insulator transition occurs at 350–400 K. Density functional theory and Monte Carlo simulations support the experimental results on the basis of anisotropic growth of vanadyl oxygen (V = O) vacancies at the surface.

GGA and GGA + U methods were also applied in a study about structural, electronic and magnetic properties of \( V_2\text{O}_5-x \) [39]. In the study the authors set \( U = 3 \text{ eV} \) and \( J = 0.9 \text{ eV} \) (\( U_{\text{eff}} = 2.1 \text{ eV} \)) in their calculations on the \( V_2\text{O}_5 \) with oxygen vacancies. They found the effect of the on-site Coulomb interaction of the V 3d electrons on the magnetic properties is not strong per oxygen vacancy.

Recently, the selective oxidation of propane on the fully oxidized \( V_2\text{O}_5(001) \) surface was studied using PBE + U [48]. In the work the on-site repulsion parameter \( U_{\text{eff}} \) was set to 6.6 eV for V on the vanadium oxide catalyst with and without titania support. It was found that the monoordinated oxygen is the most active site on the surface without and with the titania support. The bridging oxygen is more selective in the propane deshydrogenation.

GGA + U and experimental methods [49] were used in the study of the electronic structure of \( V_2\text{O}_5 \), reduced \( V_2\text{O}_5-x \) and sodium intercalated Na\( V_2\text{O}_5 \). In that study, the effective Hubbard \( U-J = 5.89 \text{ eV} \) was added for the vanadium 3d-states. They found that theoretical calculations and experimental results are in good agreement. Local density approximation (LDA + U), with similar value of \( U_{\text{eff}} \), was applied to \( \alpha \)-Na\( V_2\text{O}_5 \) [50]. This approach has produced the insulating antiferromagnetic solution with an energy gap of 2.7 eV and a magnetic moment of 0.97 \( \mu_B \) only on one type of vanadium atom. The authors indicated that their results were in satisfactory agreement with experimental results.

In the present manuscript, a number of calculations were performed in order to calculate the \( V_2\text{O}_5(001) \) surface lattice parameters, \( a \) and \( b \), and the \( V_2\text{O}_5 \) bulk lattice parameters \( (a, b \) and \( c) \), for different \( U_{\text{eff}} \) values: 0.0, 3.0 and 6.6 eV. The value \( U_{\text{eff}} = 0.0 \text{ eV} \) is chosen because is the plain DFT framework, PW91 in this manuscript. The value \( U_{\text{eff}} = 3.0 \text{ eV} \) is important because it seems to predict, or be in agreement with, the experimental energy gap between the valence and the conduction bands for the \( V_2\text{O}_5 \) bulk. The value \( U_{\text{eff}} = 6.6 \text{ eV} \) is the maximum value used in the literature (to our knowledge). One of the aims of this manuscript is to learn if one of these values of \( U_{\text{eff}} \) is the most adequate for describing the \( a \) and \( b \) lattice parameters after comparison with experimental results. It seems that none of them give a better description of the lattice parameters or, in other words, there is no strong correlation between the value of \( U_{\text{eff}} \) and the calculated surface lattice parameters \( a \) and \( b \). A comparison of the orbital energies of the \( V_2\text{O}_5(001) \) optimized surface is given for different \( U_{\text{eff}} \) values. Total and projected density of states are calculated within the GGA (PW91) + U formalism and compared for \( U_{\text{eff}} = 0.0, 3.0 \) and 6.6 eV. Despite the calculated lattice parameters, for the bulk and for the (001) surface, are not correlated with the election of \( U_{\text{eff}} \), the election of \( U_{\text{eff}} = 3.0 \text{ eV} \) seems to be the best one to describe the energy gap between the valence and the conduction bands after comparison with experimental results. After this conclusion, the stability of the V-O(1) bond is underestimated and overestimated for \( U_{\text{eff}} = 0.0 \) and 6.6 eV, respectively. However, the stability of the V-O(2) and V-O(3) bonds is not strongly correlated with \( U_{\text{eff}} \). It seems that the energy gap between the valence and the conduction bands is strongly correlated with the charge density distribution in the V-O(1) bond. Density charge distribution plots show there is an under and overestimation of the charge accumulation between the V and O(1) atoms using \( U_{\text{eff}} = 0.0 \) and 6.6 eV, respectively. The strength of the bonds, according to charge accumulation, is V-O(1) bond stronger than V-O(2) bond and V-O(2) bond stronger than O(3) bond.

2. Methodology

First-principles total energy calculations were performed using density functional theory (DFT) as implemented in the Vienna Ab initio Simulation Package (VASP) [51, 52] to investigate the structure and the electronic structure of the \( V_2\text{O}_5(001) \) surface and the \( V_2\text{O}_5 \) bulk. The Kohn-Sham equations were solved using the projector augmented wave (PAW) approach for describing electronic core states [53, 54] and a plane-wave basis set including plane waves up to 400 eV. Electron exchange and correlation energies were calculated within the generalized gradient approximation (GGA) in the Perdew-Wang (PW91) form [55]. For \( U_{\text{eff}} \) equals to 3.0 and 6.6 eV, the values 4 and 7.6 eV were given to \( U \), respectively; in both cases, \( J = 1 \text{ eV} \). \( U \) and \( J \) were not included in the \( U_{\text{eff}} = 0 \) (GGA) calculations. The Dudarev \textit{et al} approach is used [56] and, \( U \) and \( J \) are given to Vanadium only. In this approach only \( U-J=\pm U_{\text{eff}} \) is meaningful.

Each system (the \( V_2\text{O}_5(001) \) surface and vacuum, and the bulk) were modeled by a different orthorhombic supercell. In the case of the surface, the lattice parameters \( a \) and \( b \) were calculated following the iterative procedure described here, for the \( U_{\text{eff}} \) values. First step, keep the value of the \( b \) lattice parameter fixed and perform calculations to optimize the geometry of the system for different values of the \( a \) lattice parameter until the minimum energy is found. Second step, keep the \( a \) lattice parameter fixed at the value found in the first step,
3. Results and discussion

3.1. Structure of the divanadium pentoxide, bulk and (001) surface lattice parameters

The structure of the divanadium pentoxide (V$_2$O$_5$) has been investigated using different experimental and theoretical techniques [29, 30]. It has been described in previous articles ([31, 32, 34, 57] and references within) and a short description is given here. Divanadium pentoxide has an orthorhombic structure with lattice parameters $a$, $b$ and $c$. The divanadium pentoxide bulk structure is made of layers that are perpendicular to the $c$ axis, each layer is made of VO$_6$ octahedra [31] at two levels. The layers are linked vertically by corners, in the (001) plane. Figure 1 shows the surface supercell used in this manuscript, lattice parameters $a$ and $b$ of the surface and of the bulk, were allowed to relax freely according to the calculated forces applied on them. Atomic relaxations are considered converged when the forces on the ions are less than 0.01 eV Å$^{-1}$. Brillouin zone of the supercell was sampled with a $\Gamma$ centered mesh resulting in 22 irreducible $k$-points for the surface calculations and with a ($1 \times 3 \times 3$) $\Gamma$ centered mesh for the bulk case. The energies of the DOS calculations have been shifted to have the parameter E-fermi in 0.0 eV.

![Figure 1](image.png)

**Figure 1.** Clean V$_2$O$_5$(001) surface cell used in the present manuscript. The $a$ and $b$ lattice parameters of the surface cell are marked. A (1 $\times$ 2) surface is marked with the rectangle. Vanadium (V, light blue balls) and oxygen atoms (O(1), O(2) and O(3), red balls) are marked. The $x$, $y$ and $z$ axes are also indicated. The V, O(1), O(2) and O(3) atoms used in figure 5 for charge density contour plots are marked with plot and white arrows. The figure has been made with the xcrysden program [63].

Table 1. Calculated $a$ and $b$ lattice parameters (Å) for the (001) surface and $a$, $b$ and $c$ lattice parameters for the bulk structure of the V$_2$O$_5$.

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and perform geometry optimizations for different values of the $b$ lattice parameter until the minimum energy is found. Third step, keep the $b$ lattice parameter fixed at the value found in the second step, and perform geometry optimizations for different values of the $a$ lattice parameter until the minimum energy is found. Continue with this iterative procedure until the configuration of minimum energy is found for both, $a$ and $b$ lattice parameters. Similar iterative procedure was used to find $a$, $b$ and $c$ lattice parameters for the bulk for every value of the chosen $U_{eff}$. A few articles, exchange the lattice constants $b$ and $c$ and the (001) plane is named (010) plane [34]. The surface was modeled by a monolayer thick slab separated by more than 15 Å vacuum region to avoid interactions between slabs due to periodic boundary conditions in the perpendicular to the surface direction. All the atoms of the surface and of the bulk, were allowed to relax freely according to the calculated forces applied on them. Atomic relaxations are considered converged when the forces on the ions are less than 0.01 eV Å$^{-1}$. The first Brillouin zone of the supercell was sampled with a ($4 \times 10 \times 1$) $\Gamma$ centered mesh resulting in 22 irreducible $k$-points for the surface calculations and with a ($1 \times 3 \times 3$) $\Gamma$ centered mesh for the bulk case. The energies of the DOS calculations have been shifted to have the parameter E-fermi in 0.0 eV.
interaction). In this way a VO$_6$ octahedron is formed [57]. The (001) face is the most stable single-crystal surface [31, 58]. Experimental and theoretical studies have shown that the (001) surface has very similar physical properties and stability as the bulk crystal [34, 35, 48, 59–61]. Therefore, in this manuscript the substrate is modeled by a single slab that can be considered as a realistic model of the V$_2$O$_5$(001) surface. Results obtained in this manuscript support this statement. The calculated single layer electronic structure is similar to the calculated electronic structure for the bulk, for the three values of $U_{\text{eff}}$ used in this work. For the surface and for the bulk, a number of calculations were performed for different values of the lattice parameters $a$, $b$ and $c$ in order to calculate the values that minimize the energy, for every $U_{\text{eff}}$. Figure 2 shows the calculated relative energy of the V$_2$O$_5$(001) surface versus values given to the lattice parameters $a$ (top) and $b$ (bottom) around the minimum energy (in every case). The calculated values for the lattice parameter $a$ are 11.41, 11.34 and 11.36 Å using $U_{\text{eff}}$ 0.0, 3.0 and 6.6 eV, respectively. The calculated values for the lattice parameter $b$ are 3.57, 3.63 and 3.69 Å using $U_{\text{eff}}$ 0.0, 3.0 and 6.6 eV, respectively. Energy (eV) in the vertical axis and lattice parameters in the horizontal axis (Å).

Figure 2. Last step in the calculation of the lattice parameters $a$ (top) and $b$ (bottom) for different values of $U_{\text{eff}}$ 0.0 (circles), 3.0 (squares) and 6.6 (triangles) eV. The calculated values for the lattice parameter $a$ are 11.41, 11.34 and 11.36 Å using $U_{\text{eff}}$ 0.0, 3.0 and 6.6 eV, respectively. The calculated values for the lattice parameter $b$ are 3.57, 3.63 and 3.69 Å using $U_{\text{eff}}$ 0.0, 3.0 and 6.6 eV, respectively. Energy (eV) in the vertical axis and lattice parameters in the horizontal axis (Å).
the V$_2$O$_5$(001) surface. Similar conclusions are valid for the $a$ and $b$ lattice parameters for the bulk calculations. However, for every $U_{\text{eff}}$, the $a$ and $b$ lattice parameters calculated for the layer are slightly shorter than the experimental results, whereas the ones calculated for the bulk are a bit longer. The calculated $a$ lattice parameter for the bulk is $\approx 0.2$ Å longer than the calculated for the (001) surface. In the case of the $c$ lattice parameter of the bulk calculations, the van der Waals interactions are not taken into account, and the separation between layers is a bit overestimated.

The optimized V–O bond lengths of the V$_2$O$_5$(001) surface and of the V$_2$O$_5$ bulk are in good agreement between them and are not correlated with the values of $U_{\text{eff}}$ used in this manuscript ($U_{\text{eff}} = 0.0$, 3.0 and 6.6 eV), as shown in table 2. Also, there is good agreement when optimized V–O bond lengths are compared with previous published results.

### 3.2. Electronic structure of the divanadium pentoxide, bulk and (001) surface

Calculations of the electronic structure of the V$_2$O$_5$(001) surface and of the V$_2$O$_5$ bulk were performed with the calculated lattice parameters for every $U_{\text{eff}}$ value.

**Total DOS, valence band and energy gap.** Calculated total density of states (DOS) of the bulk V$_2$O$_5$ and of its (001) surface for different values of $U_{\text{eff}}$ are shown on figure 3: $U_{\text{eff}} = 0.0$, 3.0 and 6.6 eV from the top. Negative energy values and DOS larger than zero refer to the valence band and positive energy values and DOS larger than zero refer to the conduction band. In the case of the surface, at first glance, the valence band shows a large maximum around its middle region for $U_{\text{eff}} = 0.0$ eV. Although the maximum is smaller for $U_{\text{eff}} = 3.0$ eV, the general shape of the valence band is similar to the previous case (continuous lines). This maximum is due to the O(1)p$_x$ and Vd$_{\perp}$ orbitals and it is not so strong in the cases of bulk calculations (dashed lines). For $U_{\text{eff}} = 6.6$ eV, the general shape seems to be similar to the previous cases, but the maximum is not in the middle of the valence band but there is one near the bottom of the band (low energies) and another one near the top (high energies).

The width of the valence band seems not to be correlated with the value of $U_{\text{eff}}$ for the surface and for the bulk. For the surface is about 4.87, 4.75 and 4.78 eV for $U_{\text{eff}} = 0.0$, 3.0 and 6.6 eV, respectively, (in agreement with previous DFT results [33]) whereas the calculated valence band for bulk are less than 0.2 eV wider than those values. The calculated width of the valence band is then, not correlated with the value of the $U_{\text{eff}}$ at least the ones used in the present work. A wider valence band of 5.5 eV was calculated using a different computational set up in references [34] and [41] for LDA and GGA ($U_{\text{eff}} = 0$ eV). Also, the angle resolved He–II ultraviolet photoemission spectrum of a V$_2$O$_5$(001) surface sample taken at normal incidence shows a wider range of about 6 eV [41, 62].

For bulk and surface at higher energies, the calculated energy gap between the valence and the conduction bands depends on the value given to $U_{\text{eff}}$ as well as the width and shape of the conduction band. In the case of the surface, the calculated energy gaps are 1.81, 2.19 and 2.95 eV for $U_{\text{eff}} = 0.0$, 3.0 and 6.6 eV, respectively. In comparison, the energy gaps calculated for the bulk are between 0.1 and 0.2 eV smaller as shown in figure 3. Comparison with experimental values (2.0 and 2.2 eV according to references [44] and [45], respectively) shows an underestimation and overestimation of the energy gap using $U_{\text{eff}} = 0.0$ and 6.6 eV. Also, the energy gap calculated with the present computational set up is a bit higher than the one calculated in reference [43].

However, $U_{\text{eff}} = 3.0$ eV seems to be, or seems to be near, the correct value in order to describe the energy gap. The calculated widths of the conduction band are 2.34, 2.28 and 1.47 eV, for $U_{\text{eff}} = 0.0$, 3.0 and 6.6 eV, respectively, for the surface and the bulk.

**PDOS, O(1).** There is an energy shift for the $p_z$ atom projected PDOS when the $U_{\text{eff}}$ changes values. The energy shift is about 0.4 eV when $U_{\text{eff}}$ changes values from 0.0 to 3.0 eV and is about 1.4 eV when $U_{\text{eff}}$ changes values from 0.0 to 6.6 eV, figure 4. The z axis is the direction of the V–O(1) bond, figure 1. The atom projected PDOS of the O(1) contributes mainly to the middle and top parts of the valence band. The main peak for $U_{\text{eff}} = 0.0$ and 3.0 eV, see figure 3, seems to be due to a large contribution of the O(1)p$_z$ orbital (also, due to the Vd$_{\perp}$). There is no strong change in the p$_x$ and p$_y$ atom projected PDOS of the O(1), only a shift smaller than 0.2 eV of a few peaks to lower energies when the $U_{\text{eff}}$ takes values 0.0, 3.0 and 6.6 eV, complementary material.
Similar characteristics in the case of the bulk for the \( p_z \) atom projected PDOS, figure 5, but the valence band is much less neat than in the surface case, for the \( p_x \) and \( p_y \) atom projected PDOS (complementary material).

**PDOS, O(2).** In the case of the surface, there is an important contribution of the \( p_z \) orbital of the O(2) near the bottom of the valence band, figure 4. It should be notice that the \( x \) direction is (near) the V–O(2)–V bonds direction as shown in figure 1. The \( p_x \) and \( p_z \) main contributions are in the middle and top parts of the valence band (complementary material). In the \( y \) direction, the peak in the middle of the valence band seems to shift slightly towards higher energies when \( U_{\text{eff}} \) takes the values 0.0, 3.0 and 6.6 eV. This shift is stronger in the case of the bulk (complementary material). The contribution of the \( p_z \) peak to the middle of the valence band seems to

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**Figure 3.** Calculated density of states (DOS) of the clean \( V_2O_3(001) \) surface and of the \( V_2O_3 \) bulk, for different values of \( U_{\text{eff}} \): 0.0 eV (top panel, blue continuous and dashed lines), 3.0 eV (middle panel, red continuous and dashed lines) and 6.6 eV (green continuous and dashed lines). DOS in the vertical axis (number of states/unit cell), energy (eV) in the horizontal axis.
decrease for $U_{\text{eff}} = 6.6$ eV but there are not energy shift of the peaks. The peak around $-3.8$ eV in the three total DOS plot shown in figure 3 seem to be due to the O(2)p$_x$ orbital mainly, with contributions of V$d_{x^2-y^2}$ and O(3)p$_x$ orbitals. In the case to the bulk, there is a very little shift of the main peak towards higher energies when using $U_{\text{eff}} = 0.0$, 3.0 and 6.6 eV, figure 5 for the $p_x$ contribution.

PDOS, O(3). For surface and bulk, figures 4 and 5 show the $p_x$ atom projected PDOS contributes to the top and near the bottom of the valence band to the total DOS. There is a shift of $\approx 0.3$ eV near the bottom of the valence band when $U_{\text{eff}}$ increases from 0.0 to 3.0 and to 6.6 eV. The contribution to the upper part of the valence band is not correlated with $U_{\text{eff}}$. The O(3)p$_x$ atom projected PDOS contributes mainly to the bottom of the valence band and there is, also, a shift of $\approx 0.2$ eV upward in energy, when $U_{\text{eff}}$ increases from 0.0 to 3.0 and to 6.6 eV. Near the x direction there is one V-O(3) bond, whereas near the y direction there are two V-O(3) bonds. For surface and bulk, the $p_x$ atom projected PDOS contributes mainly to the top of the valence band (complementary materials), however, there is a contribution to the total DOS of the middle region in the case of the surface. There is a small projection of the V-O(3) bonds in the z direction.

PDOS, V. The contribution of the $d_{z^2}$ orbital is in the middle of the valence band and is the most important among the vanadium $d$ orbitals to the total DOS for the bulk and the surface, figures 4 and 5. In the case of the
surface, the atom projected PDOS shows a main peak that shift to lower energies, $-1.8$, $-2.1$ and $-3.3$ eV as the value of $U_{\text{eff}}$ increases $0.0$, $3.0$ and $6.6$ eV, respectively. The $z$ direction is the V-O \(^1\) bond direction, figure 1. There is not a main peak in the case of the bulk, but the general behaviour is that the peaks shift to lower energies as the $U_{\text{eff}}$ increases. Figures 4 and 5 show some contribution of the $d_{x2-y2}$ orbital to the total DOS in the lower half of the valence band, for any of the values of the $U_{\text{eff}}$ considered, for surface and bulk. The V-O(2) and V-O(3) bonds are mainly in the $x$ and $y$ directions with little projection in the $z$ direction. There is very little contribution of the $d_{xy}$, $d_{xz}$ and $d_{yz}$ orbitals to the total DOS for bulk and surface (complementary materials).

**V-O(1) bond.** Figure 4 shows, for the surface, a comparison between the atomic projected PDOS of the O(1) $p_z$ and V$d_{z2}$ orbitals for the values of $U_{\text{eff}}$ studied here. There are common features between the above mentioned orbitals. For $U_{\text{eff}} = 0.0$ eV (blue continuous line), there is a peak around $-1.8$ eV and a small band between $-2.2$ and $-3.2$ eV. For $U_{\text{eff}} = 3.0$ eV (red dashed line), there is a main peak around $-2.1$ eV and also a small band between $-2.4$ and $-3.2$ eV. And for $U_{\text{eff}} = 6.6$ eV (green dot-dashed line), there is a peak around $-3.3$ eV and a main small band between $-3.4$ and $-4.6$ eV. The comparison seems to indicate that the common features shift the energy values to the lower part of the valence band. Probably this indicates that the V-O(1) bond is more stable when the $U_{\text{eff}}$ increases its values: $0.0$, $3.0$ and $6.6$ eV. If the ‘true’ value of $U_{\text{eff}}$ is around
shows a main peak around 3.0 eV, the use of \( U \) does not depend strongly on the value assigned to \( U \). Charge density distribution in the vanadium-oxygen bonds of V\(_2\)O\(_5\) is thicker for \( U = \) 6.6 eV, where the oxygen atoms are (red, on line version). The V, O(1), O(2) and O(3) atoms used are marked on figure 1 with plot and white arrows. The figure has been made with the vesta program [65].

![Figure 6](image_url)

**Figure 6.** Calculated charge density contour plots (e/Bohr\(^3\)) for the three \( U_{\text{eff}} \) values: 0.0, 3.0 and 6.6 eV (left, central and right panels). On the left, the values of the minimum charge density plotted, the maximum charge correspond to 1.19 e Bohr\(^3\), where the oxygen atoms are (red, on line version). The V, O(1), O(2) and O(3) atoms used are marked on figure 1 with plot and white arrows. The figure has been made with the vesta program [65].

3.0 eV, the use of \( U_{\text{eff}} = 0.0 \) or 6.6 eV, underestimate or overestimate the V-O(1) bond stability. Inspection of the figure 5 for the bulk show common features of the O(1)p\(_x\) and Vd\(_{z^2}\) orbitals for the values of \( U_{\text{eff}} \) studied, although not so clear as for the surface. Also, there is a shift towards lower energies as \( U_{\text{eff}} \) increases. As for the surface, the use of \( U_{\text{eff}} = 6.6 \) or 0.0 eV, overestimate or underestimate the V-O(1) bond stability.

V-O(2) and V-O(3) bonds. From figures 4 and 5 for surface and bulk, two comparisons are going to be made looking for common features between orbitals. Atomic projected PDOS of O(2)p\(_x\) and Vd\(_{x^2−y^2}\) orbitals show a small band between −2.2 and −3.2 eV (this small band is also present in the O(1)p\(_x\) and Vd\(_{z^2}\)) and the main peak around −4 eV. These features do not depend strongly on the value assigned to \( U_{\text{eff}} \) and probably the stability of the V-O(2) bond is not correlated with \( U_{\text{eff}} \). Atomic projected PDOS of O(3)p\(_x\) and O(3)p\(_z\) orbitals are compared with the Vd\(_{x^2−y^2}\) orbital. They, also, show a small peak around −4 eV. The atomic projected DOS of O(3)p\(_y\) shows a main peak around −4.5 eV, O(3)p\(_x\) and Vd\(_{x^2−y^2}\) orbitals show a small feature at the same energy. These features do not depend strongly on the value assigned to \( U_{\text{eff}} \) and probably the stability of the V-O(3) bond is not correlated with \( U_{\text{eff}} \) either.

### 3.3. Charge density distribution in the vanadium-oxygen bonds of the V\(_2\)O\(_5\)(001) surface

Figure 6 shows the calculated density of electronic charge (e/Bohr\(^3\)) distribution around the V-O(1)-O(2)-O(3) atoms in the \( \text{zx} \) plane for \( U_{\text{eff}} \) values: 0.0, 3.0 and 6.6 eV (left, central and right panels, respectively). In these (nine) charge density diagrams the maximum correspond to 1.19 e Bohr\(^3\) and is around the oxygen atoms.

In the top three panels, the minimum electronic charge density shown is 0.16 e Bohr\(^3\). For \( U_{\text{eff}} = 0.0 \) eV there is a discontinuity in this charge density contour between the V and O(1) atoms, due to the absence of charge density larger than 0.16 e Bohr\(^3\). For \( U_{\text{eff}} = 3.0 \) and 6.6 eV the charge density contour is continuous and is thicker for \( U_{\text{eff}} = 6.6 \) eV than for \( U_{\text{eff}} = 3.0 \) eV. This is because larger charge density contours are present for \( U_{\text{eff}} = 6.6 \) eV than for \( U_{\text{eff}} = 3.0 \) eV between the V and O(1) atoms. In this way, the charge accumulation between the V and O(1) atoms is larger for \( U_{\text{eff}} = 6.6 \) eV and smaller for \( U_{\text{eff}} = 0.0 \) eV. Assuming that the near correct value for \( U_{\text{eff}} \) is 3.0 eV, the electronic charge between the V and O(1) atoms, i.e. in the V-O(1) bond, is underestimated for \( U_{\text{eff}} = 0.0 \) and 6.6 eV, respectively.

For the minimum charge density plotted of 0.10 e Bohr\(^{-3}\), the charge density distribution between the V and O(2) atoms shows that the charge accumulation in the V-O(2) bond is almost not correlated with the value of \( U_{\text{eff}} \). For the minimum charge plotted of 0.07 e Bohr\(^{-3}\), the bottom three panels show that the charge density distribution between the V and O(3) seems to be slightly correlated with \( U_{\text{eff}} \).
We compare the strength of the three bonds for every $U_{\text{eff}}$ value. For $U_{\text{eff}} = 3.0$ eV (valid for $U_{\text{eff}} = 0.0$ and 6.6 eV as well), following the ideas exposed a few lines above, from figure 6, the upper panel shows there are more charge density contours corresponding to larger than 0.16 e Bohr$^{-3}$ charge density between the V and the O(1) atoms. But there is a lack of these charge density contours between V and O(2), and also between V and O(3). This indicates that there is a larger accumulation of charge in the V-O(1) bond than in the other two V-O bonds. In consequence, the V-O(1) bond is stronger than the other two V-O bonds. The central panel shows there are charge density contours larger than 0.10 e Bohr$^{-3}$ in the V-O(2) bond but they are not present in the V-O(3) bond. Consequently, it seems that the strength of the V-O bonds is V-O(1) bond is stronger than V-O(2) bond and this is stronger than V-O(3) bond. This conclusion seems to be supported by the bottom panel, charge contour 0.07 e Bohr$^{-3}$, in which the accumulation of charge seems to be larger between the V-O(1) than between the V-O(2) and V-O(3). The charge density between V and O(3) in the (near) $y$ direction (not shown) seems to be higher than in the $x$ but still not higher than in the V-O(2) bond. So, the V-O(3) bond in the $y$ is stronger than in the $x$ direction but weaker than the V-O(2) bond.

4. Conclusions

A number of density functional theory (DFT(PW91)+U) calculations were performed to calculate the surface lattice parameters ($a$ and $b$) of the $V_2O_3$(001) surface and the $V_2O_3$ bulk lattice parameters ($a$, $b$ and $c$). $U_{\text{eff}} = 0.0$ (GGA), 3.0 and 6.6 eV were used. It seems that there is not correlation between the calculated lattice parameters and the value assigned to $U_{\text{eff}}$. This is, there is not a clear evidence that one of these values is the most adequate to describe the experimental results; there is a good agreement between the calculated lattice parameters and the experimental results.

DFT+U was, then, applied to the study of the electronic structure of the systems under investigation. The width of the valence band is not strongly correlated on the value of $U_{\text{eff}}$, it is about 4.87, 4.75 and 4.78 eV for $U_{\text{eff}} = 0.0, 3.0$ and 6.6 eV, respectively, for the surface. The calculated energy gap between the valence and the conduction bands shows correlation with the chosen values for $U_{\text{eff}} \approx 1.81, 2.19$ and 2.95 eV for $U_{\text{eff}} 0.0, 3.0$ and 6.6 eV, respectively. $U_{\text{eff}} = 3.0$ eV seems to be the most adequate value to describe the $V_2O_3$ bulk and its (001) surface following the comparison of the calculated energy gap with the experimental results. The V-O(1) bond stability seems to be under and over estimated for $U_{\text{eff}} = 0.0$ and 6.6 eV. The stability of the V-O(2) and V-O(3) bonds does not seem to be strongly correlated with the election of the $U_{\text{eff}}$. According to the calculated charge distribution, for any of the used $U_{\text{eff}}$ values, the V-O(1) bond is stronger than the V-O(2) bond and this is stronger than the V-O(3) bonds. It seems that the energy gap between the valence and the conduction bands is strongly correlated with the charge density distribution in the V-O(1) bond, mainly.

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